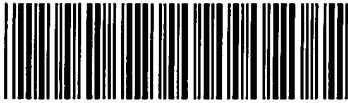


Search Notes

Application No.

10/712,923

Examiner

Toan Ton

Applicant(s)

IWASA ET AL.

Art Unit

2871

SEARCHED

| Class | Subclass | Date | Examiner |
|-------|----------|-----------|----------|
| 349 | 137 | 9/30/2004 | TTON |
| | 113 | | |
| | 44 | | |
| 313 | 503 | | |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |

INTERFERENCE SEARCHED

| Class | Subclass | Date | Examiner |
|-------|----------|------|----------|
| | | | |
| | | | |
| | | | |
| | | | |

**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

| | DATE | EXMR |
|---|-----------|------|
| EAST liquid crystal reflect\$ anti reflect\$ black mask/matrix light shield\$/block\$ insulat\$/passivat\$ oxygen silicon metal\$5 | 9/30/2004 | TTON |
| tft capacit\$ | | |
| | | |
| | | |
| | | |
| | | |
| | | |
| | | |
| | | |
| | | |
| | | |
| | | |
| | | |